Temperature studies of Urbach absorption edge in implanted Cu₆PS₅Br crystals

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Abstract

 Cu_6PS_5Br crystals grown with a chemical vapour transport technique are implanted with sulphur ions. Optical absorption edge for the implanted crystals is studied in the temperature range of 77–320 K. Temperature dependences of the optical pseudogap and the Urbach energy are analysed. The parameters of exciton-phonon interaction resulting from the Urbach behaviour of the optical absorption edge are determined. Ordering-disordering processes in Cu_6PS_5Br crystals induced by the ion implantation are studied.

Keywords: superionic conductors, implantation, phase transitions, Urbach absorption edge, structural disorder

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1. Introduction

Cu₆PS₅Br crystals belong to the family of compounds with an argyrodite structure [1]. They are characterised by high concentration of disordered vacancies and manifest both superionic and ferroelastic properties. High ionic conductivity at the room temperature [2, 3] stipulates different possibilities for their practical applications as solid electrolyte sources of energy, sensors, and highly efficient capacitors.

Cu₆PS₅Br crystals belong to the cubic syngony (the space group $F\overline{4}3m$) at the room temperature and two phase transitions (PTs) occur at lower temperatures: a ferroelastic one at $T_{II} = (268\pm2)$ K and a superionic one at $T_I = (166-180)$ K [2]. Below the ferroelastic PT temperature, Cu₆PS₅Br crystals are monoclinic (the space group *Cc*), while the superionic PT reveals some features of an isostructural transformation [4]. Anomalous behaviours of the calorimetric, acoustic and optical properties have been revealed in the region of the PTs [5–8]. The studies of the optical absorption edge in Cu₆PS₅Br have shown the existence of excitons below the superionic PT temperature, which undergo considerable changes with increasing temperature. The PT into superionic state results not only in variations of the exciton structure, but also in appearance of exponential regions at the long-wavelength absorption edge. The temperature behaviour of those exponential regions at $T > T_I$ is known to be described by the empirical Urbach rule [8].

The present work is aimed at the studies of influence of ion implantation on the Urbach absorption edge in superionic Cu_6PS_5Br conductors and the role of orderingdisordering processes occurring in the crystal lattice in the formation of the absorption edge.

2. Experimental

Single Cu_6PS_5Br crystals were grown using a chemical vapour transport technique [2]. A standard experimental set-up with magnetic separation was used for the implantation. The angle of incidence was equal to 10° and the sulphur ion energy was 150 keV. The implantation of the Cu_6PS_5Br crystals was performed using a ${}^{32}S^+$ isotope obtained from a sulphur powder heated above 400°C and delivered in the gaseous state to the ion source.

Spectral dependences of the absorption coefficient α were studied in the temperature range of 77–320 K. The samples prepared for the transmittance and reflectance measurements were oriented at the room temperature while staying in their cubic phase. The linear absorption coefficient α as a function of transmittance, T_{tr} , and the reflectance of the surface, R, were calculated using the well-known formula which takes multiple internal reflections of light into account:

$$\alpha = \frac{1}{d} \ln \left\{ \frac{(1-R)^2}{2T_{tr}} + \sqrt{\left[\frac{(1-R)^2}{2T_{tr}}\right]^2 + R^2} \right\},\tag{1}$$

with *d* denoting the thickness of a plane-parallel sample. The experimental setup and the working technique have been described elsewhere (see, e.g., [2]). The relative error $\Delta \alpha / \alpha$ for determining the absorption coefficient does not exceed 10% at the conditions given by $0.3 \le \alpha d \le 3$ [9].

3. Results and discussion

The temperature studies of the optical absorption edge have shown that, like in the case of unimplanted Cu_6PS_5Br crystals, the shape of the absorption edge of the implanted crystals is exponential and follows the Urbach rule [10]:

$$\alpha(h\nu, T) = \alpha_0 \exp\left[\frac{\sigma(h\nu - E_0)}{kT}\right] = \alpha_0 \exp\left[\frac{h\nu - E_0}{E_U(T)}\right],$$
(2)

where E_U is the Urbach energy, σ the slope parameter of the absorption edge, α_0 and E_0 the coordinates of the convergence point of the Urbach bundle, *k* the Boltzmann constant, *T* the temperature, and *hv* the photon energy. As an example, Fig. 1 presents the spectral dependences of the absorption coefficient at different temperatures for the case of Cu₆PS₅Br crystal implanted with the fluence of 1×10¹⁵ ions/cm². Similar Urbach bundles have been observed for all of the implanted crystals. The coordinates α_0 and E_0 of the

convergence point of the Urbach bundle for the unimplanted crystal and the crystals implanted with different fluences are gathered in Table 1. It should be noticed that the coordinates α_0 and E_0 of the convergence point remain unchanged in the region of the secondorder structural PT (i.e., near the temperature point $T = T_{II}$).

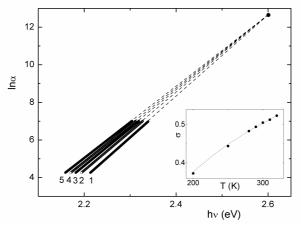


Fig. 1. Spectral dependences of Urbach absorption edge obtained at different temperatures for the Cu₆PS₅Br crystal implanted with the fluence of 1×10^{15} ions/cm²: 1 – 200, 2 – 250, 3 – 280, 4 – 300, and 5 – 320 K. The insert shows temperature dependence of the slope parameter σ .

Table1. Parameters of the Urbach absorption edge, parameters of the EPI and the PT temperatures for the unimplanted and implanted Cu₆PS₅Br crystals at $T > T_{II}$. The α_0 , E_0 and E_g^* , and E_U values are determined with the errors of $\pm 3 \times 10^5$ cm⁻¹, $\pm 5 \times 10^{-4}$ eV, and $\pm 2 \times 10^{-4}$ eV, respectively.

$\pm 2 \times 10^{-1}$ eV, respectively.						
Crystal	Unim-	1×10^{11}	1×10^{12}	1×10^{13}	1×10^{14}	1×10^{15}
	planted	ions/cm ²				
E_{g}^{*} (300K)	2.275	2.278	2.285	2.292	2.300	2.306
(eV)						
<i>E_U</i> (300K)	56.3	47.0	46.0	48.6	48.8	51.3
(meV)						
$\alpha_0 \ (\text{cm}^{-1})$	3.7×10 ⁵	3.3×10 ⁵	3.1×10 ⁵	3.0×10 ⁵	3.5×10 ⁵	3.1×10 ⁵
E_0 (eV)	2.609	2.548	2.550	2.573	2.585	2.601
σ_0	0.664	0.818	0.812	0.755	0.779	0.745
$\hbar \omega_p \text{ (meV)}$	62.6	65.5	62.4	60.5	64.4	64.9
θ_{E} (K)	726	760	724	702	747	753
$(E_U)_0$ (meV)	47.2	40.1	38.4	40.0	41.3	43.8
$(E_U)_1$ (meV)	94.1	79.8	76.9	80.0	82.6	84.5
$E_g^*(0)$ (eV)	2.323	2.320	2.331	2.339	2.345	2.352
S_g^*	7.84	7.55	7.48	7.25	7.63	7.93
$T_{\rm II}({\rm K})$	265.6±0.5	267.6±0.5	269.4±0.5	269.0±0.5	268.5±0.5	268.5±0.5

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Following from our analysis of the Urbach absorption edge, the optical pseudogap E_g^* and the Urbach energy E_U have been obtained (see Fig. 2). Here the E_g^* parameter means the absorption edge energy position taken at a fixed value of the absorption coefficient ($\alpha = 10^3 \text{ cm}^{-1}$ in our case), while E_U is the energy width of the exponential absorption edge. It has been revealed that the optical pseudogap E_g^* increases as a result of ion implantation. On the other hand, the Urbach energy E_U decreases for the fluence values less than $1 \times 10^{12} \text{ ions/cm}^2$ and increases if the latter exceed $1 \times 10^{12} \text{ ions/cm}^2$. This testifies that the small fluences initiate some crystal lattice ordering processes, while in case of the fluences larger than $1 \times 10^{12} \text{ ions/cm}^2$ we deal with lattice disordering.

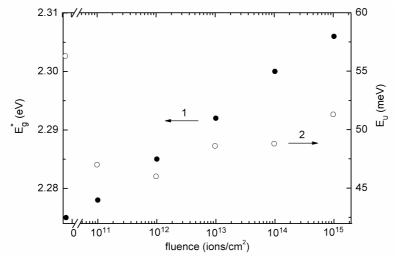


Fig. 2. Dependences of optical pseudogap E_g^* (1) and Urbach energy E_U (2) on the fluence value for the implanted Cu₆PS₅Br crystals. The sizes of the symbols of experimental data points exceed the error bars which are $\pm 5 \times 10^{-4}$ eV for E_g^* and $\pm 2 \times 10^{-4}$ eV for E_U .

Exponential shape of a long-wavelength tail of the absorption edge is usually attributed to an exciton-phonon interaction (EPI) [11]. In the whole temperature interval under study, both the implanted and unimplanted Cu₆PS₅Br crystals manifest the temperature dependences of the slope parameter σ described by the Mahr relation [11]:

$$\sigma(T) = \sigma_0 \left(\frac{2kT}{\hbar\omega_p}\right) \tanh\left(\frac{\hbar\omega_p}{2kT}\right),\tag{3}$$

where σ_0 is a constant independent of temperature, which is related to the EPI constant g ($\sigma_0 = 2/3g$), and $\hbar \omega_p$ denotes an average effective phonon energy in a single-oscillator model describing the EPI [11]. An example of such dependence is presented in the insert of Fig. 1. It is worthwhile that the inequality $\sigma_0 < 1$ indicating a strong EPI (see [12]) holds true for the both implanted and unimplanted Cu₆PS₅Br crystals. The values of the

effective phonon energy $\hbar \omega_p$ and the σ_0 parameter are given in Table 1. It is seen that both the σ_0 and $\hbar \omega_p$ parameters first increase with increasing fluence (by 23% and 5%, respectively), then decrease (for the fluence values less than 1×10¹³ ions/cm²) and eventually increase weakly (for the fluences exceeding 1×10¹³ ions/cm²).

Among numerous theoretical treatments of the Urbach rule, a model of self-trapped exciton by Sumi and Toyozava (ST) [13] and a microelectric-field theory (a so-called internal Franz-Keldysh effect) by Dow and Redfield (DR) [14] are the most often cited. In our earlier work [2] we have shown that the mechanism of EPI in Cu₆PS₅Br crystals is well explained in the framework of the DR theory. According to the latter, broadening of excitonic maxima that occurs with increasing temperature and a resulting exponential absorption edge are associated with the interaction of excitons with microelectric fields generated by LO phonons [14]. In order to check whether the DR theory could also describe the EPI in the implanted Cu₆PS₅Br crystal, we have applied the procedure suggested in the study [15]. Here influence of the external electric field F_e causing the internal Franz-Keldysh effect is replaced by the root-mean square value of the phonon-induced internal electric field F_p , thus leading to the expression

$$E_g^* \tanh\left(\frac{\hbar\omega_p}{2kT}\right) = E_g^*(0) - E_0 \left[1 - \tanh\left(\frac{\hbar\omega_p}{2kT}\right)\right],\tag{4}$$

where $E_g^*(0)$ is the band gap at zero temperature. A linear relation between $E_g^* \tanh(\hbar \omega_p / 2kT)$ and $[1 - \tanh(\hbar \omega_p / 2kT)]$ depicted in Fig. 3 supports a qualitative agreement between the DR theory and the absorption processes in these crystals.

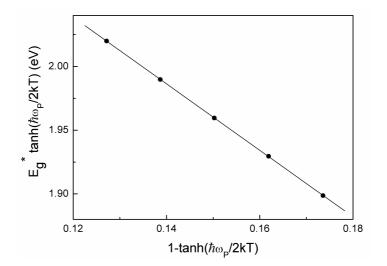


Fig. 3. Illustration of linear relation between the parameters $E_g^* \tanh(\hbar \omega_p / 2kT)$ and $[1 - \tanh(\hbar \omega_p / 2kT)]$ taking place for the Cu₆PS₅Br crystal implanted with the fluence of 1×10¹⁵ ions/cm² (*T* > *T*_{II}).

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Temperature dependences of the optical pseudogap E_g^* and the Urbach energy E_U for the Cu₆PS₅Br crystal implanted by sulphur ions with the fluence of 1×10¹⁵ ions/cm² are shown in Fig. 4. We are to emphasise that, due to the EPI, the temperature behaviour of E_g^* seen in Fig. 4 can be described in frame of the Einstein model by the relation [16]

$$E_{g}^{*}(T) = E_{g}^{*}(0) - S_{g}^{*}k\theta_{E} \left[\frac{1}{\exp(\theta_{E}/T) - 1} \right],$$
(5)

where $E_g^*(0)$ is the energy gap at 0 K, S_g^* a dimensionless constant, and θ_E the Einstein temperature corresponding to the average frequency of phonon excitations of a system of non-coupled oscillators. The calculations performed by us prove that the experimental E_g^* values are well described by Eq. (5). The $E_g^*(0)$, S_g^* and θ_E parameters obtained for the unimplanted and implanted crystals are given in Table 1, whereas a solid line shown in Fig. 4 represents the temperature dependence of the optical pseudogap E_g^* calculated basing on Eq. (5) for the Cu₆PS₅Br crystal implanted with the fluence of 1×10^{15} ions/cm².

It is well known that the Urbach energy E_U in frame of the Einstein model is described as [17]

$$(E_U) = (E_U)_0 + (E_U)_1 \left[\frac{1}{\exp(\theta_E / T) - 1} \right], \tag{6}$$

where $(E_U)_0$ and $(E_U)_1$ are constants. The values of $(E_U)_0$ and $(E_U)_1$ obtained by fitting Eq. (6) to the experimental temperature dependences of E_U for the unimplanted and implanted crystals are also listed in Table 1. The temperature dependence of the Urbach energy E_U for the Cu₆PS₅Br crystal implanted with the fluence of 1×10¹⁵ ions/cm² is shown in Fig. 4 as a dashed line.

In [18] it has been shown that both the temperature-related effect and the structural disordering affect the shape of the Urbach absorption edge, so that the Urbach energy E_U is described by the relation

$$E_U = (E_U)_T + (E_U)_X = (E_U)_T + (E_U)_{X,stat} + (E_U)_{X,dyn},$$
(7)

where $(E_U)_T$ and $(E_U)_X$ are respectively the temperature-related and structural disordering contributions to E_U , while $(E_U)_{X,stat}$ and $(E_U)_{X,dyn}$ imply the contributions of static structural disordering and dynamic structural disordering to $(E_U)_X$, respectively.

The static structural disordering $(E_U)_{X,stat}$ in the Cu₆PS₅Br crystal is caused by structural imperfection due to high concentration of disordered copper vacancies, while the dynamic disordering $(E_U)_{X,dyn}$ is concerned with intense motion of mobile copper ions participating to the ion transport, which is responsible for ionic conductivity [8]. One should notice that the first term in the right-hand side of Eq. (6) represents the static structural disordering and the second one – the temperature-related types of disordering. These are the temperature disordering due to thermal lattice vibrations and the dynamic structural disordering linked with the presence of mobile ions in superionic conductors.

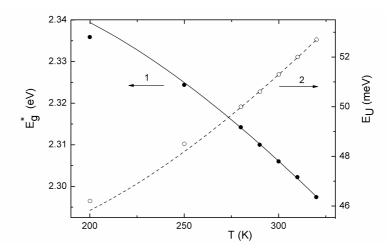


Fig. 4. Temperature dependences of optical pseudogap E_g^* (curve 1) and Urbach energy E_U (curve 2) for the Cu₆PS₅Br crystal implanted with the fluence of 1×10¹⁵ ions/cm²: circles correspond to the experiment and curves to the calculations. Solid and dashed lines are obtained by using Eqs. (5) and (6) for fitting the experimental data, with the parameters listed in Table 1. The sizes of the symbols of experimental data points exceed the error bars $(\pm 5 \times 10^{-4} \text{ eV} \text{ for } E_g^* \text{ and } \pm 2 \times 10^{-4} \text{ eV} \text{ for } E_U$).

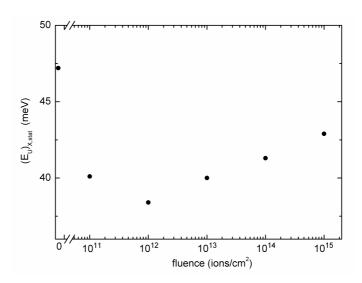


Fig. 5. Dependence of contribution of the static structural disordering $(E_U)_{X,stat}$ to the Urbach energy E_U on the fluence value for the implanted Cu₆PS₅Br crystals.

We have evaluated contribution of the static structural disordering to the Urbach energy E_U for the implanted Cu₆PS₅Br crystals. As one can see from Fig. 5, the absolute value of that contribution decreases initially with increasing fluence, reaches a minimum at the fluence of 1×10^{12} ions/cm², and then increases again. At the fluence of 1×10^{15} ions/cm² it amounts to 93 per cent of the absolute value of contribution of the static structural disordering for the unimplanted crystal (see Fig. 5 and Table 1).

4. Conclusions

Cu₆PS₅Br single crystals grown with the chemical vapour transport technique have been implanted with different fluences of 150 keV ³²S⁺ ions. The optical absorption edges for the both unimplanted and implanted Cu₆PS₅Br crystals have exponential shapes, following the well-known Urbach rule. The temperature behaviour of the Urbach absorption edge is determined by the EPI, which is strong enough in both the unimplanted and implanted crystals. The temperature dependences of the optical pseudogap E_g^* and the Urbach energy E_U are successfully obtained. They are well described by the theoretical curves calculated in the framework of the Einstein model. We have also shown that the ordering processes take place in the crystal lattice for the fluences less than 1×10^{12} ions/cm², while the fluence values larger than 1×10^{12} ions/cm² cause disordering of the lattice.

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Анотація. Кристали Cu₆PS₅Br, вирощені методом газотранспортних реакції і імплантовані іонами сірки. Досліджений край оптичного поглинання імплантованих кристалів в температурному діапазоні 77–320 К. Проаналізовані температурні залежності забороненої зони і енергії Урбаха. На основі урбахівської поведінки краю оптичного поглинання визначені параметри екситон-фоннонної взаємодії. В кристалах Cu₆PS₅Br досліджений процес впорядкування - розупорядкування, індукований іонною імплантацією.